

272b Microfabrication of Mesoporous Silica Films for MemS Applications

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Chip-scale devices are of great interest mainly due to their portability and novel functionality.¹ One of the key components in such devices is functional porous film nanostructure. Despite recent development in silicon-based microelectromechanical systems (MEMS) technology, with current top-down micromachining it is still a technological challenge to fabricate such porous functional nanostructure in cost-effective ways. Self-assembled mesoporous silica films can be an alternative to creating such nanostructure in a simple and controlled manner since they can be easily coated using conventional coating techniques² (for instance, spin-coating and dip-coating), readily functionalized with functional organic groups, and are compatible with current silicon microfabrication technology.³ Self-assembled mesoporous silica materials (in the form of powder or film) have drawn a great deal of research interest over the last decade.^{4,5} Their unique pore structures of nanometer dimension enable them to find applications in separation, catalysis, encapsulation, chemical/biological sensing, low-dielectric coatings, and optical thin films. In order to use the mesoporous films for MEMS applications as novel nanostructures, one has to solve several challenging problems. Such problems include: 1) to deposit continuous films of thickness of several micrometers in a facile way and 2) to fabricate self-standing films by microfabrication techniques for certain MEMS applications such as micro fuel cells. In this talk, we will introduce a new way to prepare continuous mesoporous films of 2-3 micrometer thick using a lamp-based rapid thermal processing technique. We will also talk about the preparation of self-supporting mesoporous films on a silicon wafer using microfabrication techniques. The characterization of the microstructures of the mesoporous films will be presented. The functionality of the self-supporting mesoporous films will be demonstrated by fabricating direct formic acid micro fuel cells and measuring performance.

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